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Pressure-InducedMetallizationoftheMottInsulatorMnO

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Abstract

High-pressureelectricalconductivityexperimentshavebeenperformedontheMott insulatorMnOtoamaximumpressureof106GPa.Weobserveasteadydecreaseinresistivity to90GPa,followedbyalarge,rapidd ecreasebyafactorof10 ⁵between90and106GPa. Temperaturecyclingthesampleat87and106GPashowsinsulatingandmetallicbehaviorat thesepressures,respectively.Ourobservationsprovidestrongevidenceforapressure -induced Mottinsulator -to-metaltransitionwithanaccompanyingmagneticcollapsebeginningat90GPa.

Introduction

The electronic structures of the transition metal monoxides Mno, CoO, and NiO exhibit localization of their 3 delectronic due to a combination of strong electronic due to a combination of strong electronic due to a combination of the 3 delectronic shells in these compounds to make the mmetal lic, all of these transition metal monoxides are in fact robust Mottin sula tors due to correlation - induced localization of their charge carriers at the Fermiener gy. The study of strongly correlated systems such as MnO is of interest because large electronic - electron correlation effects are recognized to be important features of high-T c superconductors 1, many magnetic systems 2 (e.g. heavy Fermions), and geophysically important materials in the Earth's interior.

MnOisanantiferromagnetic(T _N=122K)ioniccrystalwiththeB1(rocksalt)structure ²⁺ionsofthisstructurepossesshalf atambient conditions. The Mn -filled3d ⁵shells,whichform intoahigh -spinHund'srulestateof ⁶Sforafreeion.However,intheactualoctahedralcrystal ²⁺ioninMnO,the5 fieldenvironmentsurroundingeachMn -foldorbitaldegeneracyofthe 3d levelispartiallyliftedandtheindividual3dstatesaresplitintotriplydegeneratet 2ganddoubly degeneratee glevels. Since this crystal fields plitting for MnO($\Delta E_{CF} \approx 1 \text{ eV}$)remainssmaller thantheHund'sruleexchangesplitting($\Delta E_{EX} \approx 4.5 \text{eV}$), parallelelectronspinalignment is favored, and the high -spinnature of the 3 delectrons is retained. In this state, all of the parallel spinstatesofthet 2gande glevelsaresinglyoccupied,andtheremaining,oppositespinstatesare completelye mpty(⁶A_{1g}crystalfieldgroundstate).

 $The degree to which a system will tend to exhibit correlation -induced Mottlocalization of electrons can be characterized by means of two parameters in the Hubbard model: (1) the Coulombre pulsion energy U for two electrons on the same atomic site; and, (2), the effective electronic bandwidth W. Mottlocalization is expected in narrow band systems when the ratio U/W exceeds a critical value. Many -body Monte Carlosimulations have predicted that this critical value eisgiven by \sqrt{N}, or 2.24 for the d -band, where N is the orbital degeneracy. \(^{3,4}$ For MnOatambient pressure, the Hubbard U is about 7.8 eV and the effective band width W is about

 $1eV for a U/W ratio of 7.8, mak ing MnO astrong Mottin sulator. \\ ^{3,5} Indeed, experimental values for the energy gap of MnO range from 3.8 to 4.2 eV \\ ^{6,7} confirming that MnO is a wide \\ ^{-} gap Mottin sulator at zero pressure. \\ \\ ^{8}$

PressureEffects

The application of high pressure stends to increase the overlap between electronic wavefunctions and broadens the electronic bands, causing a decrease in the U/W ratio and the eventual delocalization of the electrons. High - pressure electrical conductivity experiments are an ideal method for observing the onset of delocalization, and have been recently used to study the metallization of the Mottin sulators NiI 2, and Fe 2O3 at 19 and 50 GP are spectively.

Insomecases, ametal -to-insulator transition may be accompanie dby a structural transition. Previous experiments have demonstrated a similar sequence of structural transitions existsinseveralrock -salt-structuredtransitionmetalmonoxides.Inaddition,recentfirst principlescalculations ³haveshownthatforsometransitionmetalmonoxides,therequisite pressureformagnetic collapse and metallization could be as high as 230 GPa, and may indeed correspondtoobservedstructuraltransitions.ForMnO,previoushigh -pressurediamo ndanvil cell(DAC)x -raydiffractionstudieshavefoundthatitundergoesaseriesofstructuralphase transformationswithincreasingpressure. Thesequence B1 (rocksalt) \rightarrow distortedB1 \rightarrow unidentified \rightarrow B8(NiAs)wasobservedwithtransitionpressures of30,90,and120GPa ¹¹reportedthatatpressurestartingfromaround80GPa respectively. 11 Furthermore, Kondoetal. atroomtemperature, the MnOsample started to take on a metallic luster, eventually beco ming indistinguishablefromthestainlesssteelgasketby100GPa.Fromthis,theysuggestedthat MnOismetallicabove90GPa.ShockwavecompressionexperimentsonMnOhaverevealed thatitundergoesan8% volumecollapseatapressureof90GPaandan estimatedtemperatureof -Vcurve. ¹²ElectricalconductivityexperimentsonMnOunder 1000 °ContheshockHugoniotP shock compression up to 50 GP are vealed no evidence of metallization to this pressure.addition, recent simulations predict magnetic collapse in MnOat 149GPa, and stabilization of themetallicB8(NiAs)phase ¹⁴atpressuresabove120GPa.InordertoconfirmthatMnOdoes indeedmetallizeunderstaticpressureofaround1Mbar,weperformedhigh -pressureelectrical conductivityexperimentsonMnOinaDACtoamaximumpressureof106GPa.

Experiment

Weperformedtwo insitu electricalconductivityexperimentsonMnOinaDAC,oneto 90GPa, and one to 106GPa. Mn Opowder of 99.5% purity was obtained from Alfa Aesar, and loadedintoaDAC(KyowaSeisakushoCo.screw -type). The first experiment employed diamondswith200 -300 µmculetflats, while in the second experiment culetflats of 140 μm wereused. Inbothcases, samples were loaded in pre -indentedspringsteelgaskets,andsample chambers of 100 - 110 and 75 - 80 \(\text{µmweredrilled for the first and second experiments} \) respectively. No pressure medium was loaded in order to maximize sample volume and ensure goodelectricalcontact.Rubychipsof10 -15 µmwereloadedineachcellasapressuremarker (wedenotetheexperimentsusingrubyasapressuremarkerasRun1andRun2a secondexperimentrespectively); however, in the secondrun, pressures above 80 GPawere -raydiffractionspectrawiththex -raydiffractionspectraand calculatedbycomparisonofourx MnOequation -of-state(EOS)ofKondoetal. ¹¹(Run2b).Bymatchingthepositionsofour

diffractionpeakstothecorrespondingdiffractionpeaksofKondoetal.,wewereabletoleast squares-fiteachdiffractionspectrumtoapressure,independentofcrystal structure(since individualMnOpeakpositionsareknownasafunctionofrubypressure structure(since peakshavenotbeenindexedtoanidentifiedstructurefor90GPa<P<120GPa). Energy dispersivex -raydiffractionwasperformedonbeamlineX -17CoftheNationalSynchrotron LightSource, BrookhavenNationalLaboratory.

Electricalconductivitymeasurementsweremadevia "designer" diamondanvilsineach DAC.Designerdiamondanvilsareindividuall vfabricateddiamondanvilsinwhichthin -film tungstenmicroprobesareencapsulatedwithinalayerofhigh -quality, single -crystal, epitaxial -pressureelectricalconductivity diamond.Designeranvilshavebeenfabricatedforhigh experiments as wellasf or magnetic susceptibility experiments. ¹⁵Details of the fabrication of Thedesigneranvilusedinourexperimentis theseanvilshavebeendiscussedelsewhere. showninFigure1.Theeightmicroprobesare10 µmwideand0.5 µmthick,andareexposed onlyatthesurfacenearthecenterofthediamondanvil'sflatinordertomakeelectricalcontact withtheMnOsample.Elsewhere,theelectricalprobesarecoveredbyabout10 -50 µmof epitaxialdiamond, which serves to electrically insulate the micropro besfromthemetalgasket and also to protect them from damaged ue to shearing as the DAC is pressurized.

Forlargevaluesofresistance(R>1k Ω), two-proberesistancemeasurements were made using a Quad Tech 1865 Megohmmeter, while for smaller resistan ces(R<1k Ω) a four-probe technique was employed. The four-probe measurements were made by passing a DC current through a Keithley 2400 sourcemeter, with voltages measured via a Keithley 2182 Nanovolt meter. Over a certain range of resistances in the vicinity of 1k Ω , both methods were used, enabling us to normalize the data from the two measurement techniques to each other. A closed cycle Hecryostat (Cryomech ST15) was used to examine the temperature dependence of the resistance at specific pressures.

Results

Insitu measurementsofthesampleresistancearesummarizedinFig.2. Theinitial sampleisanopaquegreenish -blackpowderthatisinsulatingwitharesistanceontheorderof5x $10^8~\Omega$. Compressionofthesampleproducesagradualdecrease inresistancetoavaluebetween 10^3 and $10^{-2}~\Omega$ at 80 GPa. Slight variations in the rate of decrease in resistance appear to depend on sample preparation and geometry. Further compression in the range P>85 GParesults in the rapid decrease of the resistance of the sample by five orders of magnitude, reaching a final value of 7-8x $10^{-3}~\Omega$ at 106.4 GPa. This resistance corresponds to an estimated resistivity of about $40~\Omega$ -cm, which is typical of a metal.

Figures3and4showthesampleresistancever sustemperatureat87and106GPa, respectively.At87GPa(Fig.3)theresistancebehaviorshowsalargeincreasewithdecreasing temperature,indicativeofthermalactivationofcarriersacrossagap. Theinsetshowslog(R)vs. 1/T,whichgivesanene rgygapof0.16eV,basedonsimpleexponentialbehavior. Theinsulator tometaltransitioniscompleteby106GPa,andthemetallicbehaviorofthesampleisclearly evidentinFig.4,withdR/dT>0.Inbothcases,weattributeminorvariationsfromli near (metallic)orexponential(insulating)behaviortoslightchangesinpressurewithtemperature.

Discussion

 $Our observation of a large, rapid drop in the resistivity of the Mottin sulator Mn One ar 90\,$ GPastronglysupportspreviousclaimsofmetall izationbasedonopticalobservations disappearanceofRamanpeaks. ¹⁸Theonsetofarapiddropinresistivityatabout90GPa etal. 11 coincides with the appearance of the unidentified intermediate phase reported by Kondo SinceithasbeenpredictedthattheMottinsulator -to-metaltransitionofMnOisaccompaniedby alargevolumecollapse ³, and since the accumulated evidence for a Mot ttransitionat90GPais nowverystrong, wesuggest that there may be avolume collapse at 90 GPa. From an 11, we conjecture that the examinationoftheEOSdataofKondoetal. ΔV/V_omagnitudeofthe volumecollapsemaybearound 12%, although the actual structure of the phase immediately above90GPahasnotyetbeenidentified.

The decrease in the nearest neighbor distances of MnO with increasing pressures can be a constant of the decrease of the decexpected to have the effect of both increasing the amount of crystal fields plitting (ΔE_{CF}) and increasing the effective (3d) bandwidth W. In the first case, if the crystal fields plitting exceeds theHund'sruleexchangeenergyfavoringthehigh -spinstate,thenthsystemmaycollapsetoa low-spinstate.Inthesecondcase.ifthebandwidthWincreasestothepointthattheU/Wratio becomessmallenough(≈2.24ford -bandelectrons),thesystemmaythenundergoaMott insulator-to-metaltransition. Eitherofth eseeffectscouldconceivablyresultinthepressure inducedmagneticcollapseofthehigh -spinstateofMnO, althoughonly the latternecessarily involvesmetallization.Basedongeneralizedgradientapproximation(GGA)calculations,Cohen etal. ³havearguedthatthepressure -inducedmagneticcollapsesofMnO,FeO,CoO,andNiOare all driven by broadening of the effective electronic bandwidth Wanda Mottinsulatortransitionratherthananincreaseincrystalf ieldsplitting, which they claim is only a small effect. Ourobservationofasharpmetallictransitionstartingat90GPaisconsistentwiththis viewthat anincreaseinbandwidthdrivesamagnetic collapsetransition due to electron delocalization. Wefind, however, that the onset of metallization in MnOoccurs at a pressure considerably belowthepredictedtransitionpressureof149GPa, which was based on the assumption of a B1 (rocksalt)structureforboththehigh -andlow -spinphases.³

Conclusions

Wehaveperformed *in-situ*high -pressureelectricalconductivitymeasurementsonMnO toamaximumpressureof106GPa.Startingat90GPa,theresistivityundergoesafiveorder -of-magnitudedrop,completeby106GPa. Inaddition,theinsulatingandmetallicbehaviorofthe MnOsamplewasconfirmedupontemperaturecyclingat87and106GPa,respectively.Our observationsstronglysupportapressure -inducedMottinsulator -to-metaltransitionwith accompanyingmagneti ccollapseinMnObeginningatapressureof90GPa.

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⁻subbandtod -subbandexcitation.andthecharge -transferenergyD ⁸SincetheCoulombcorrelationenergyUford for2p -bandtoupperd -bandexcitationarecalculatedtobesimila rinsizeforMnO(U=8.5eV,D=8.8eV accordingtoRef. 6),thereissomequestionwhetherMnOisaMottinsulatorinthenarrowsenseorwhetheritisa charge-transferinsulator, or amixture of both.

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Captions

FIG.2Resistancevs.pressureofMnO.Pressuresweremeasuredusingrubyasaninternal standardforRun1andRun2a,whileinRun2bpressureswerecalculatedbycomparisonwithx raydiffractionspectra. TemperaturecyclesAandBcorrespondFigs.3and4respectively.

FIG.3Resistancevs.temperatureuponcoolingat86.8GPa.Thesampleshowsinsulating behaviorcommensuratewithaneffectivegapof0.16eV.

FIG.4MetallicbehaviorofMnO.Resist ancedatawerecollectedoncoolingofthesampleat 106.4GPa.







